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# NOTICE OF ALLOWANCE AND FEE(S) DUE

22204 7590 11/14/2008 NIXON PEABODY, LLP 401 9TH STREET, NW SUITE 900 WASHINGTON DC 20004-2128 DUONG, KHANH B

ART LINIT PAPER NUMBER

2822 DATE MAILED: 11/14/2008

ĺ	APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
•	10/771,277	02/04/2004	Shunpei Yamazaki	740756-2710	2066

TITLE OF INVENTION: METHOD OF MANUFACTURING A DISPLAY DEVICE USING DROPLET EMITTING MEANS

APPLN. TYPE	SMALL ENTITY	ISSUE FEE DUE	PUBLICATION FEE DUE	PREV. PAID ISSUE FEE	TOTAL FEE(S) DUE	DATE DUE
nonprovisional	NO	\$1510	\$300	\$0	\$1810	02/17/2009

THE APPLICATION IDENTIFIED ABOVE HAS BEEN EXAMINED AND IS ALLOWED FOR ISSUANCE AS A PATENT. PROSECUTION ON THE MERITS IS CLOSED. THIS NOTICE OF ALLOWANCE IS NOT A GRANT OF PATENT RIGHTS. THIS APPLICATION IS SUBJECT TO WITHDRAWAL FROM ISSUE AT THE INITIATIVE OF THE OFFICE OR UPON PETITION BY THE APPLICANT. SEE 37 CFR 1.313 AND MPEP 1308.

THE ISSUE FEE AND PUBLICATION FEE (IF REQUIRED) MUST BE PAID WITHIN THREE MONTHS FROM THE MAILING DATE OF THIS NOTICE OR THIS APPLICATION SHALL BE REGARDED AS ABANDONED. THIS STATUTORY PERIOD CANNOT BE EXTENDED. SEE 35 U.S.C. 151. THE ISSUE FEE DUE INDICATED ABOVE DOES NOT REFLECT A CREDIT FOR ANY PREVIOUSLY PAID ISSUE FEE IN THIS APPLICATION. IF AN ISSUE FEE HAS PREVIOUSLY BEEN PAID IN THIS APPLICATION (AS SHOWN ABOVE), THE RETURN OF PART B OF THIS FORM WILL BE CONSIDERED A REQUEST TO REAPPLY THE PREVIOUSLY PAID ISSUE FEE TOWARD THE ISSUE FEE NOW DUE.

#### HOW TO REPLY TO THIS NOTICE:

I. Review the SMALL ENTITY status shown above.

If the SMALL ENTITY is shown as YES, verify your current SMALL ENTITY status:

A. If the status is the same, pay the TOTAL FEE(S) DUE shown above.

B. If the status above is to be removed, check box 5b on Part B - Fee(s) Transmittal and pay the PUBLICATION FEE (if required) and twice the amount of the ISSUE FEE shown above, or

If the SMALL ENTITY is shown as NO:

A. Pay TOTAL FEE(S) DUE shown above, or

B. If applicant claimed SMALL ENTITY status before, or is now claiming SMALL ENTITY status, check box 5a on Part B - Fee(s) Transmittal and pay the PUBLICATION FEE (if required) and 1/2 the ISSUE FEE shown above.

II. PART B - FEE(S) TRANSMITTAL, or its equivalent, must be completed and returned to the United States Patent and Trademark Office (USPTO) with your ISSUE FEE and PUBLICATION FEE (if required). If you are charging the fee(s) to your deposit account, section "4b" of Part B - Fee(s) Transmittal should be completed and an extra copy of the form should be submitted. If an equivalent of Part B is filed, a request to reapply a previously paid issue fee must be clearly made, and delays in processing may occur due to the difficulty in recognizing the paper as an equivalent of Part B.

III. All communications regarding this application must give the application number. Please direct all communications prior to issuance to Mail Stop ISSUE FEE unless advised to the contrary.

IMPORTANT REMINDER: Utility patents issuing on applications filed on or after Dec. 12, 1980 may require payment of maintenance fees. It is patentee's responsibility to ensure timely payment of maintenance fees when due.

#### PART B - FEE(S) TRANSMITTAL

# Complete and send this form, together with applicable fee(s), to: Mail Commissioner for Patents P.O. Box 1450 Alexandria, Virginia 22313-1450

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INSTRUCTIONS: This form should be used for transmitting the ISSUE DEE and DURI ICATION DEE (if required). Blocks 1 through 5 should be completed where

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22204	7590	11/14/2008		EXAMINER			
NIXON PEAI	BODY, I	LLP	DUONG, KHANH B				
401 9TH STRE	ET, NW		ART UNIT	PAPER NUMBER			
SUITE 900 WASHINGTO	N, DC 20	004-2128		2822 DATE MAILED: 11/14/200	8		

# Determination of Patent Term Adjustment under 35 U.S.C. 154 (b)

(application filed on or after May 29, 2000)

The Patent Term Adjustment to date is 307 day(s). If the issue fee is paid on the date that is three months after the mailing date of this notice and the patent issues on the Tuesday before the date that is 28 weeks (six and a half months) after the mailing date of this notice, the Patent Term Adjustment will be 307 day(s).

If a Continued Prosecution Application (CPA) was filed in the above-identified application, the filing date that determines Patent Term Adjustment is the filing date of the most recent CPA.

Applicant will be able to obtain more detailed information by accessing the Patent Application Information Retrieval (PAIR) WEB site (http://pair.uspto.gov).

Any questions regarding the Patent Term Extension or Adjustment determination should be directed to the Office of Patent Legal Administration at (571)-272-7702. Questions relating to issue and publication fee payments should be directed to the Customer Service Center of the Office of Patent Publication at 1-(888)-786-0101 or (571)-272-4200.

# Application No. Applicant(s) 10/771,277 YAMAZAKI ET AL. Notice of Allowability Examiner Art Unit KHANH B. DUONG 2822 -- The MAILING DATE of this communication appears on the cover sheet with the correspondence address--All claims being allowable, PROSECUTION ON THE MERITS IS (OR REMAINS) CLOSED in this application. If not included herewith (or previously mailed), a Notice of Allowance (PTOL-85) or other appropriate communication will be mailed in due course. THIS NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT RIGHTS. This application is subject to withdrawal from issue at the initiative of the Office or upon petition by the applicant. See 37 CFR 1.313 and MPEP 1308. This communication is responsive to the amendment filed on September 30, 2008. The allowed claim(s) is/are 2,3,5,6,14,15,17,18,20,21,27 and 28. 3. Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f). b) ☐ Some\* c) ☐ None of the: a) 🛛 All 1. A Certified copies of the priority documents have been received. 2. Certified copies of the priority documents have been received in Application No. 3. Copies of the certified copies of the priority documents have been received in this national stage application from the International Bureau (PCT Rule 17.2(a)). \* Certified copies not received: \_\_\_\_\_. Applicant has THREE MONTHS FROM THE "MAILING DATE" of this communication to file a reply complying with the requirements noted below. Failure to timely comply will result in ABANDONMENT of this application. THIS THREE-MONTH PERIOD IS NOT EXTENDABLE. A SUBSTITUTE OATH OR DECLARATION must be submitted. Note the attached EXAMINER'S AMENDMENT or NOTICE OF INFORMAL PATENT APPLICATION (PTO-152) which gives reason(s) why the oath or declaration is deficient. CORRECTED DRAWINGS (as "replacement sheets") must be submitted. (a) Including changes required by the Notice of Draftsperson's Patent Drawing Review (PTO-948) attached 1) hereto or 2) to Paper No./Mail Date (b) including changes required by the attached Examiner's Amendment / Comment or in the Office action of Paper No./Mail Date Identifying indicia such as the application number (see 37 CFR 1.84(c)) should be written on the drawings in the front (not the back) of each sheet. Replacement sheet(s) should be labeled as such in the header according to 37 CFR 1.121(d). 6. DEPOSIT OF and/or INFORMATION about the deposit of BIOLOGICAL MATERIAL must be submitted. Note the attached Examiner's comment regarding REQUIREMENT FOR THE DEPOSIT OF BIOLOGICAL MATERIAL. Attachment(s) 1. | Notice of References Cited (PTO-892) 5. Notice of Informal Patent Application 2. Notice of Draftperson's Patent Drawing Review (PTO-948) Interview Summary (PTO-413), Paper No./Mail Date Information Disclosure Statements (PTO/SB/08). 7. T Examiner's Amendment/Comment Paper No./Mail Date 4. T Examiner's Comment Regarding Requirement for Deposit 8. X Examiner's Statement of Reasons for Allowance of Biological Material 9. ☐ Other .

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## DETAILED ACTION

## Response to Amendment

This office action is in response to the amendment filed on September 30, 2008.

 $Accordingly, claims \ 1, \ 4, \ 10, \ 11, \ 16, \ 19, \ 23 \ and \ 24 \ were \ canceled. \ Claims \ 7-9, \ 12, \ 13,$ 

22, 25 and 26 were previously canceled.

Currently, claims 2, 3, 5, 6, 14, 15, 17, 18, 20, 21, 27 and 28 remain pending.

## Allowable Subject Matter

Claims 2, 3, 5, 6, 14, 15, 17, 18, 20, 21, 27 and 28 are allowed.

The following is an examiner's statement of reasons for allowance: none of the prior art of record, taken alone or in combination, fairly shows or suggests all the limitations as claimed.

Re claim 2, none of the prior art of record discloses the following limitations in combination with the rest of the limitations in the claims: selectively forming a pattern including a metal material by use of droplet emitting means; selectively forming a resist by use of droplet emitting means, over the pattern; etching the pattern by use of atmospheric plasma; and ashing the resist by use of atmospheric plasma processing means after etching the pattern, wherein the droplet emitting means comprises a droplet emitting head in which a plurality of droplet emitting holes are disposed in a line form.

Re claim 3, none of the prior art of record discloses the following limitations in combination with the rest of the limitations in the claims: selectively forming a pattern including a metal material by use of droplet emitting means; selectively forming a resist by use of droplet emitting means; etching the pattern by use of atmospheric plasma processing means; and ashing the resist by use of atmospheric plasma processing means, wherein the droplet emitting means

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comprises a droplet emitting head in which a plurality of droplet emitting holes are disposed in a line form.

Re claim 5, none of the prior art of record discloses the following limitations in combination with the rest of the limitations in the claims: selectively forming a pattern including a metal material by use of droplet emitting means; selectively forming a resist by use of droplet emitting means, over the pattern; etching the pattern by use of atmospheric plasma for carrying out local plasma processing; and ashing the resist by use of plasma processing means for carrying out local plasma processing, after etching the pattern, wherein the droplet emitting means comprises a droplet emitting head in which a plurality of droplet emitting holes are disposed.

Re claim 6, none of the prior art of record discloses the following limitations in combination with the rest of the limitations in the claims: selectively forming a pattern including a metal material by use of a droplet emitting means; selectively forming a resist by use of a droplet emitting means, over the pattern; etching the pattern by use of plasma processing means for carrying out local plasma processing; and ashing the resist by use of plasma processing means for carrying out local plasma processing, after etching the pattern, wherein the droplet emitting means comprises a droplet emitting head in which a plurality of droplet emitting holes are disposed.

Re claim 14, none of the prior art of record discloses the following limitations in combination with the rest of the limitations in the claims: wherein the source electrode and drain electrode are formed by: selectively forming a first pattern including a metal material by use of droplet emitting means; selectively forming a first resist by use of droplet emitting means, over

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the first pattern; etching the first pattern by use of atmospheric plasma; and ashing the first resist by use of atmospheric plasma processing means after etching the first pattern, wherein the source electrode and the drain electrode are formed by: selectively forming a second pattern including a metal material by use of droplet emitting means; selectively forming a first pattern including a metal material by use of droplet emitting means; selectively forming a first resist by use of droplet emitting means, over the first pattern; etching the first pattern by use of atmospheric plasma; and ashing the first resist by use of atmospheric plasma processing means after etching the first pattern, wherein the source electrode and the drain electrode are formed by: selectively forming a second pattern including a metal material by use of droplet emitting means.

Re claim 15, none of the prior art of record discloses the following limitations in combination with the rest of the limitations in the claims: wherein the gate electrode is formed by: selectively forming a first pattern including a metal material by use of droplet emitting means; selectively forming a first resist by use of droplet emitting means, over the first pattern; etching the first pattern by use of atmospheric plasma for carrying out local plasma processing; and ashing the first resist by use of plasma processing means for carrying out local plasma processing, after etching the first pattern, wherein the source electrode and the drain electrode are formed by: selectively forming a second pattern including a metal material by use of a droplet emitting means; selectively forming a second resist by use of a droplet emitting means, over the second pattern; etching the second pattern by use of plasma processing means for carrying out local plasma processing; and ashing the second resist by use of plasma processing means for carrying out local plasma processing; and ashing the second resist by use of plasma processing means for carrying out local plasma processing, after etching the second pattern, wherein the droplet

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emitting means comprises a droplet emitting head in which a plurality of droplet emitting holes are disposed in a line form.

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance"

## Conclusion

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Khanh B. Duong whose telephone number is (571) 272-1836. The examiner can normally be reached on Monday-Friday from 8:30-4:30 PM.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Zandra Smith, can be reached on (571) 272-2429. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

/Zandra V. Smith/ Supervisory Patent Examiner, Art Unit 2822

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